

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	28	(polymer near3 nanotube) and (treatment treat\$3 pretreat\$3 pretreatment posttreat\$3 posttreatment heat\$3 expos\$3 anneal\$3 bak\$3 reflux\$3 extract\$3) near12 (benzene toluene xylene acetone chloroform cyclohexane alkane methanol ethanol hexane (diethyl adj ether) (ethyl adj acetate) ((organic solvent) adj (vapor vapour)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/23 20:37
L2	268	(polymer plastic organic) near3 (flow\$3 infiltrat\$3 reflow\$3) near12 (benzene toluene xylene acetone chloroform cyclohexane alkane methanol ethanol hexane (diethyl adj ether) (ethyl adj acetate) ((organic solvent) adj (vapor vapour)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/23 20:56
L3	33	2 and (nano\$20)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/23 21:03
L4	168	(polymer plastic) near3 (flow\$3 infiltrat\$3 reflow\$3) near12 (vapor vapour)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/23 20:56
L5	17	4 and (nano\$20)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/23 20:56
L6	17	5 not 3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/23 21:01
L7	2585	solvent near3 (plastici?ation plasticis\$3 plasticiz\$3) near12 (polymer plastic resin epoxy)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/23 21:30
L8	95	7 and (nano\$20)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/23 21:31

L9	12	7 and (nanotube fullerene)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/23 21:34
L10	88	8 not 9	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/23 21:27
L11	17	10 not plasticizer	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/23 21:27
L12	234	(gas vapor) near3 (plasticization plasticis\$3 plasticiz\$3) near12 (polymer plastic resin epoxy)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/23 21:34
L13	0	12 and (nanotube fullerene)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/23 21:31
L14	14	12 and (nano\$20)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/23 21:31
L15	2836	(gas vapor) near3 (soften\$3 flow\$3 reflow\$3) near6 (polymer plastic resin epoxy)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/23 21:40
L16	22	15 and (nanotube fullerene)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/23 21:34
L17	309	(gas vapor) near3 (soften\$3 flow\$3 reflow\$3) near6 (polymer plastic resin epoxy) near12 (opening hole trench via groove space)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/23 21:41
L18	46	17 and (nm nanometer micron micrometer mu)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/23 21:42

L19	316	(gas vapor) near3 (soften\$3 flow\$3 reflow\$3 plastici?ation plasticis\$3 plasticiz\$3) near6 (polymer plastic resin epoxy) near12 (opening hole trench via groove space)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/23 21:42
L20	46	19 and (nm nanometer micron micrometer mu)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/23 21:42